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APPLICATION NO. FILING DATE		FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.		
09/832,978	04/12/2001	Hideo Kitagawa	35.C15293	9731		
5514	7590 09/25/2002					
	CK CELLA HARPER	EXAM	EXAMINER			
30 ROCKEFI NEW YORK	ELLER PLAZA , NY 10112	OLSEN, A	OLSEN, ALLAN W			
			ART UNIT	PAPER NUMBER		
			1763	4		
			DATE MAILED: 09/25/2002	DATE MAILED: 09/25/2002		

Please find below and/or attached an Office communication concerning this application or proceeding.

		a.5		Anglianni(a)	WK-4
	•	Applicati n N .		Applicant(s)	
	Office Action Summary	09/832,978		KITAGAWA ET AL	
	Onice Action Summary	Examin r		Art Unit	
	The MAILING DATE of this communication ap	Allan W. Olsen	sheet with the c	1763	iress
Period fo		pears on the cover	· ·	orrespondence due	,,,,,,,,,,,,,,,,,,,,,,,,,,,,,,,,,,,,,,,
THE I - External after - If the - If NC - Failu - Any r	ORTENED STATUTORY PERIOD FOR REPL MAILING DATE OF THIS COMMUNICATION. Insions of time may be available under the provisions of 37 CFR 1. SIX (6) MONTHS from the mailing date of this communication. Period for reply specified above is less than thirty (30) days, a replayend for reply is specified above, the maximum statutory period reto reply within the set or extended period for reply will, by statutely received by the Office later than three months after the mailing a patent term adjustment. See 37 CFR 1.704(b).	136(a). In no event, howe ly within the statutory min will apply and will expire e, cause the application to	over, may a reply be time imum of thirty (30) days SIX (6) MONTHS from to become ABANDONE	ely filed s will be considered timely. the mailing date of this con 0 (35 U.S.C. § 133).	
1)⊠	Responsive to communication(s) filed on 12	<u> April 2001</u> .			
2a) <u></u> ☐	This action is FINAL . 2b)⊠ T	his action is non-fi	nal.	•	
3)□	Since this application is in condition for allow closed in accordance with the practice under				e merits is
· _	on of Claims	_			
-	Claim(s) <u>1-20</u> is/are pending in the applicatio 4a) Of the above claim(s) is/are withdra		ation		
	, , , ,	iwii iroini considera	ation.		
	Claim(s) is/are allowed.				_
	Claim(s) <u>1-20</u> is/are rejected. Claim(s) is/are objected to.				
	Claim(s) is/are objected to: Claim(s) are subject to restriction and/e	or alaction require	mont		
•	on Papers	or election requires	Hent.		,
9)[2]	The specification is objected to by the Examino	er.			
10)	The drawing(s) filed on is/are: a)□ acce	epted or b)⊡ objecto	ed to by the Exar	niner.	
	Applicant may not request that any objection to the	ne drawing(s) be hel	d in abeyance. Se	ee 37 CFR 1.85(a).	
11) 🔲 -	The proposed drawing correction filed on	_ is: a)∏ approve	ed b) disappro	ved by the Examine	r.
•	If approved, corrected drawings are required in re	eply to this Office act	ion.		
12) 🗌 🗀	The oath or declaration is objected to by the E	xaminer.			
Priority u	ınder 35 U.S.C. §§ 119 and 120				
13)⊠	Acknowledgment is made of a claim for foreig	n priority under 35	U.S.C. § 119(a))-(d) or (f).	
a)[☑ All b)☐ Some * c)☐ None of:		* *		
	1. Certified copies of the priority documen	ts have been rece	ived.		
	2. Certified copies of the priority documen	ts have been rece	ived in Application	on No	•
* S	3. Copies of the certified copies of the price application from the International Business the attached detailed Office action for a list	ureau (PCT Rule 1	7.2(a)).		Stage
	cknowledgment is made of a claim for domest		•		application).
_a) The translation of the foreign language pracknowledgment is made of a claim for domes	ovisional application	on has been rec	eived.	
Attachment					
2) Notice 3) Inform	e of References Cited (PTO-892) e of Draftsperson's Patent Drawing Review (PTO-948) nation Disclosure Statement(s) (PTO-1449) Paper No(s) 2	4)		(PTO-413) Paper No(s atent Application (PTO	
.S. Patent and Tr PTO-326 (Re		ction Summary		Part of	Paper No. 4

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DETAILED ACTION

Specification

The disclosure is objected to because of the following informalities:

page 3, line 4 - "2" should be --3--;

page 8, lines 8-13 - this paragraph/sentence is not clear;

page 10, line 23 - After allowed patent application 09/082,006 issues the specification should refer to the patent number.

Appropriate correction is required.

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

Claims 1-4, 6-15 and 17-20 are rejected under 35 U.S.C. 103(a) as being unpatentable over U. S. Patent 6,037,255 issued to Hussein et al. (hereinafter, Hussein).

Hussein teaches a method of patterning an organic dielectric layer (103). Hussein teaches applying a patterned photoresist to a hard mask layer (104) that overlies the organic dielectric. After exposing a portion of the organic layer, Hussein teaches that the exposed portion is removed by plasma etching, wherein the plasma gas contains N₂ and H₂. Hussein teaches the organic layer is a polymer. Hussein teaches the use of low k dielectric polymers such as FLARETM and polyarylethers (column 2, line 57 - column 3, line 6). Hussein teaches using a hard mask material that comprises titanium (column lines 37-38 and column 2, lines 43-49). Hussein also discloses the utility of tantalum in the barrier/mask layers (column 3, line 63).

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Claims 5 and 16 are rejected under 35 U.S.C. 103(a) as b ing unpat ntable over Hussein as applied to claims 1 and 11 above and further in view of Suzuki to al. in EP 0880164 (hereinafter, Suzuki).

Hussein does not teach using a surface-wave interfered plasma.

Suzuki teaches using a surface-wave interfered plasma.

It would have been obvious to one skilled in the art to use a surface-wave interfered plasma because Suzuki teaches that this provides a uniform high density plasma over a large area. Additionally a higher quality plasma processing can be accomplished at lower temperatures over a wider pressure range (column 4).

Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Allan Olsen whose telephone number is 703-306-9075. If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Greg Mills, can be reached on 703-308-1633.

The examiner's Right-Fax (direct to desktop) phone number is 703-872-9684.

Alternatively, the general fax numbers for TC1700 are 703-872-9310 (non-after finals) and 703-872-9311(after-final).

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the Group receptionist whose telephone number is (703) 308-0661.

Allan Olsen, Ph.D. September 15, 2002

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